Nanograting-based compact vacuum ultraviolet spectrometer and beam profiler for in situ characterization of high-order harmonic generation light sources

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A compact, versatile device for vacuum ultraviolet (VUV) beam characterization is presented. It combines the functionalities of a VUV spectrometer and a VUV beam profiler in one unit and is entirely supported by a standard DN200 CF flange. The spectrometer employs a silicon nitride transmission nanograting in combination with a microchannel plate-based imaging detector. This enables the simultaneous recording of wavelengths ranging from 10 to 80 nm with a resolution of 0.25–0.13 nm. Spatial beam profiles with diameters up to 10 mm are imaged with 0.1 mm resolution. The setup is equipped with an in-vacuum translation stage that allows for in situ switching between the spectrometer and beam profiler modes and for moving the setup out of the beam. The simple, robust design of the device is well suited for nonintrusive routine characterization of emerging laboratory- and accelerator-based VUV light sources. Operation of the device is demonstrated by characterizing the output of a femtosecond high-order harmonic generation light source. © 2010 American Institute of Physics. [doi:10.1063/1.3443575]

I. INTRODUCTION

Novel vacuum ultraviolet (VUV) light sources are the tools of the trade of a fast growing scientific community that extends the field of ultrafast real-time studies into photon energy regimes beyond the realm of conventional femtosecond lasers. In particular laboratory-scale setups that employ the technique of high-order harmonic generation (HHG) driven by an intense infrared (IR) femtosecond laser allow for a new class of time-domain experiments using moderately intense femtosecond and even attosecond duration VUV light pulses. Prominent examples for this emerging field of ultrafast science are the direct determination of an atomic inner-shell hole lifetime, the real-time monitoring of unimolecular dissociation dynamics, the observation of delayed photoemission from solids, quantum state-resolved probing of aligned electron holes created by strong-field ionization, and the real-time observation of electron tunneling.

Despite the widespread application of HHG-based VUV light sources in fundamental research, to the best of our knowledge, no design has been reported for a compact, nonintrusive tool for in situ characterization of two of the most important characteristics of a VUV light beam: the photon energy spectrum and the spatial beam profile. This is in stark contrast to the established field of ultrafast research in the IR/visible regime, which heavily relies on in situ beam characterization using commercially available spectrometers and beam profilers. VUV spectrometers are of course ubiquitous in many research laboratories and designs have been reported that are specifically tailored toward the detection of HHs. In general, however, these spectrometers are designed and built to become a stationary part of the experiment, i.e., the recorded spectrum is the experimental result. This often leads to a layout that makes it difficult to use the spectrometer as a fast diagnostic for a VUV light beam that is used for different experiments, such as photoelectron or ion spectroscopy. Owing to the small ratio between the short wavelengths of VUV radiation and standard grating constants, the size of a VUV spectrometer is usually on the scale of ∼1 m, contributing a significant fraction to the overall laboratory footprint of the experiment. Mobile optics that permit to route the VUV beam either into the experiment or the spectrometer are often incompatible with the requirement for interferometric stability in experiments such as attosecond time-resolved spectroscopy.

Here, we present a highly sensitive VUV beam analyzer that combines the functionalities of a spectrometer and a beam profiler in a single compact unit that can readily be implemented in most experimental setups. It employs a transmission nanograting in combination with a microchannel plate (MCP) based imaging detector. The entire unit is mounted on a standard DN200 CF vacuum flange; the in-vacuum dimensions are less than 200×200×100 mm³ (length×width×height). Wavelengths ranging from 10 to 80 nm are recorded simultaneously with a resolution that varies from 0.25 to 0.13 nm across the spectral range. Beam profiles with diameters up to 10 mm are imaged with 0.1 mm resolution. The sensitivity of the device is adjustable; the upper limit reaching the single photon counting regime. The large dynamic range in combination with a low background noise enables the characterization of a large variety of VUV light sources. All in-vacuum components are mounted on a remote-controlled translation stage. Switching between the
operating modes of the beam analyzer as well as the removal of the unit from the VUV beam path is completed within minutes. The design removes any impact of the beam analysis on the alignment of experimental components and effectively decouples the precision of the stage motion from the spectrometer resolution.

The functionality of the VUV spectrometer and beam profiler is demonstrated by characterizing the output of a HHG light source that is based on a loosely focused IR driving pulse and a differentially pumped gas cell. An elliptical VUV beam profile is observed. Numerical simulations of coherent beam propagation show that it is the result of a commonly used astigmatic driver focusing geometry. Adjusting the temporal chirp of the driving IR laser leads to significant changes in the HH spectrum including splitting of HH peaks. The spectral structures may be due to interference effects in the single atom response to chirped driver pulses as recently described by Liu et al.\textsuperscript{11}

\section{II. DESIGN}

A photograph of the device is shown in Fig. 1; the main components are sketched in Fig. 2. All elements of the spectrometer and beam profiler except for the digital camera are mounted on a standard optical breadboard. The breadboard is attached to a linear translation stage with 50 mm maximum travel distance (Newport 436). For increased vacuum compatibility, the stage is disassembled, anodized surface layers are removed, and the crossed roller bearing lubricant is replaced by a vacuum-compatible grease (Apiezon L). The entire setup is mounted on a standard DN200 CF vacuum flange, facilitating quick integration of the device into existing experimental setups. The stage position is controlled by a high vacuum compatible piezoactuator (Newport Picomotor 8303-V) that facilitates remote in-vacuum switching between spectrometer [Fig. 2, position (a)] and beam profiler [Fig. 2, position (b)] modes and clearing the VUV beam axis by \(\sim 10\) mm for experiments that require light downstream from the spectrometer. In spectrometer and beam profiler modes, the VUV beam enters the setup through 30 mm long tubes with 10 mm inner diameter in order to limit the amount of background light in the system.

In spectrometer mode, the beam passes through the 50 \(\mu\)m wide entrance slit and is incident on the transmission nanograting at an angle of 0\(^\circ\) (normal to the grating plane). The SiN transmission grating (nm\textsuperscript{2} LLC) used in this setup was developed by Savas et al.\textsuperscript{12,13} The grating is composed of free-standing 44 nm wide bars with a 100 nm periodicity, leaving 56 nm wide spaces between the bars. The bars are developed from a 200 nm thick SiN membrane by achromatic lithography.\textsuperscript{12,13} For improved mechanical stability of the grating, the vertical bars are intercepted by horizontal support structures spaced by approximately 1.5 \(\mu\)m. The small period of the grating facilitates a compact spectrometer design with a resolution of 0.25–0.13 nm at wavelengths of 10 and 80 nm, respectively.

In beam profiler mode, the VUV beam is incident on the imaging detector at angles of 30\(^\circ\) horizontally and 0\(^\circ\) vertically. To correct for the effect of this geometry on the beam profile, the detector image is scaled horizontally by a factor of \(\sqrt{3}/2\) during the analysis.

The imaging detector (Beam Imaging Solutions) consists of two resistance-matched imaging quality MCPs (Burle Photonis) in chevron configuration combined with an aluminized P-20 phosphor screen. The active area of the round detector is 40 mm in diameter. The detector is attached to the optical breadboard with a home-built mount equipped with a polytetrafluoroethylene (PTFE)-lined cable clamp to minimize stress on the high-voltage contacts during motion. In order to minimize variations of detection efficiency across the imaging detector in the dispersive plane due to differences in photon incidence angles, the MCP stack is aligned such that the channels are tilted in the vertical plane only.

\begin{figure}[h]
\centering
\includegraphics[width=\linewidth]{fig1.png}
\caption{(Color online) VUV spectrometer and beam profiler device mounted on a DN200 CF flange.}
\end{figure}

\begin{figure}[h]
\centering
\includegraphics[width=\linewidth]{fig2.png}
\caption{In spectrometer mode (a), the VUV beam passes through the entrance tube, the 50 \(\mu\)m wide entrance slit, and is dispersed by the transmission grating. The diffraction pattern is detected by the MCP-phosphor screen assembly and imaged onto a digital camera through a DN63 viewport by means of an Al mirror. In beam profiler mode (b), the VUV beam passes through an entrance tube and is directly incident on the MCP detector. The direction of motion of the translation stage is indicated by the double arrow.}
\end{figure}
Uncoated, rimless 1.5 mm thick MCPs with 25 μm nominal pore size and 8° bias angle convert incident photons into electron bunches that are accelerated onto the phosphor screen.

The front of the MCP assembly is mounted at a distance of L=45 mm from the center of the diffraction grating. The detector surface normal is tilted relative to the VUV beam propagation direction by θ₀=30° (Fig. 2). The fluorescence of the phosphor screen is imaged through a DN63 CF vacuum viewport onto a zoom lens equipped digital camera by means of an enhanced Al utility mirror (Newport). In the present setup, the 1280×1024 pixels complementary metal-oxide semiconductor camera (Edmund Optics) is used in integration mode. The zoom lens is adjusted to image a 44 mm wide area onto the camera corresponding to a pixel limited resolution of 35 μm. With single-shot detection and centroiding analysis, the uncertainty due to electron bunch size can be reduced down to the MCP pore size of approximately 25 μm.

Performance of the spectrometer and beam profiler is demonstrated by characterizing a VUV beam produced by HHG in Ar and Kr (Fig. 3). An intense femtosecond IR laser beam is generated by routing the output of a mode-locked Ti:sapphire laser through a cryogenically cooled two-stage amplifier system (Red Dragon, KM Laboratories). The IR beam with a diameter of 20 mm is focused into a target cell filled with noble gases at pressures of several millibars. The cell is terminated by 50 μm thick Al filter and an image integration time of 30 s. Potential differences of 1450 V across the MCP stack and 2350 V by means of an enhanced Al utility mirror (Newport) maintains a pressure difference of about six orders of magnitude between the gas cell and the surrounding vacuum chamber. The strong IR field (up to 10^14 W/cm²) ionizes the target gas. Field-driven electron-ion recollision and recombination lead to emission of radiation at frequencies equal to odd integer multiples of the fundamental laser frequency. The maximum achievable photon energy depends on the maximum peak power of the focused laser pulse and the ionization potential of the gas. HH light emerges from the cell collinearly with the driver laser beam and is separated from the co-propagating IR by two reflections from superpolished pure silicon mirrors under Brewster angle geometry for the IR beam, and subsequent passage through an aluminum filter. To avoid detector saturation, a set of aluminum filters of various thicknesses (100 nm–7 μm) are mounted on an in-vacuum manipulator that is separate from the spectrometer assembly.

**III. DIFFRACTION FROM A TRANSMISSION NANORATING**

The compact design of the spectrometer voids the application of small angle approximations and leads to geometry-induced variations of the spectral sensitivity. In the following, equations are derived that are needed to extract relative spectral intensities from the experimental images. In addition, they are used for the precise determination of the detector position with respect to the diffraction grating, as described in the next section.

For a normal incidence geometry, the diffraction angle θ for the nth diffraction order is given by

\[
\sin \theta = \frac{\lambda}{d},
\]

where λ is the wavelength of the incident light and d=100 nm is the period of the grating. A typical diffraction pattern is shown in Fig. 4(a). It is recorded using a 4 μm thick Al filter and an image integration time of 30 s. Potential differences of 1450 V across the MCP stack and 2350 V between the stack and the phosphor screen are applied. The VUV beam is generated using 25 fs duration IR driving pulses (785 nm) with 3.6 mJ pulse energy. The HHG gas cell is filled with Ar at a stagnation pressure of 5.3 mbars. The vertical lines in the image correspond to the signal from individual harmonics separated by 3.2 eV (twice the 1.6 eV photon energy of the IR driving laser).

The individual harmonic traces seen in Fig. 4(a) are vertically elongated. Their detailed structure is better resolved in Fig. 5(a), which is recorded using a 100 nm thick Al filter. The central part of the image is strongly saturated; the upper and lower parts display a series of vertically displaced maxima for each harmonic with a characteristic crescent

![Image of the diffraction pattern of a femtosecond VUV light beam recorded using a 4 μm thick aluminum filter. (b) Spectrum extracted from (a) by analysis of the two-dimensional diffraction pattern as described in the text.](image-url)
shape. This pattern is caused by diffraction of the VUV light on the periodic support structure of the grating as discussed by Wilheim et al. The period of the support structure is about 1.5 μm and thus the first order diffraction angle at a wavelength of 50 nm is 1.9° corresponding to a vertical displacement of approximately 1.5 mm on the detector screen.

To understand the crescent shape of the diffraction patterns of individual harmonics, it is necessary to consider diffraction in two dimensions (Fig. 6). Let \( \vec{k} \) be the wavevector of the diffracted light and \( k_x, k_y, k_z \) its components along the three Cartesian axes: the \( z \) axis is pointing along the beam direction, the \( y \) axis is pointing vertically along the grating bars, and the \( x \) axis is pointing horizontally to the right when looking along the \( z \) axis. Due to energy conservation, the length of the wavevector remains unchanged upon diffraction.

Diffraction in two dimensions can be described by a change in the wavevector direction in the horizontal and vertical planes equal to integer multiples of the reciprocal periods of the grating and the support structure

\[
\Delta \vec{k} = n_x \vec{e}_x \frac{2\pi}{d_x} + n_y \vec{e}_y \frac{2\pi}{d_y}.
\]

Here, \( \vec{e}_x \) and \( \vec{e}_y \) are the unit vectors in the corresponding directions, \( n_x \) and \( n_y \) are the diffraction orders, and \( d_x \) and \( d_y \) are the periods of the grating and the support structure, respectively. For gratings with open aperture ratios close to 50%, second order diffraction maxima are strongly suppressed. Therefore, only the case of \( n_x=1 \) will be discussed in the following. It is straightforward to generalize the results to higher diffraction orders.

By definition, the components of the incident wavevector along the \( x \) and \( y \) axis are equal to zero and thus the diffracted beam components are equal to the corresponding projections of \( \Delta \vec{k} \). The third component \( k_z \) is determined by energy conservation

\[
k_z^2 = k^2 - k_x^2 - k_y^2.
\]

The diffraction angle in the horizontal plane is given by the ratio of the two wavevector projections

\[
\tan(\theta_x) = \frac{k_x}{k_z}.
\]

In the case of additional vertical diffraction, increasing values of \( k_y \) lead to a decrease of \( k_z \) according to Eq. (3) and thus to larger values of the horizontal diffraction angle \( \theta_x \) in Eq. (4). As shown in Fig. 6, the resulting curvature of the first order diffraction maximum of a single harmonic is given by the curvature of a section of a sphere of radius \( k \). The two-dimensional diffraction patterns can be calculated by intersecting the directions of the diffraction maxima with the detector plane positioned at a distance \( L \) from the center of the grating with the angle \( \theta_0 \) between the surface normal and the VUV beam direction

\[
x = \frac{Lk_y}{k_z \sin \theta_0 + k_z \cos \theta_0},
\]

\[
y = \frac{k_y}{k_x} x.
\]

To analyze the spectra recorded by the camera, it is more convenient to transform these equations into a coordinate system in the detector plane. Let \( u \) be the horizontal coordinate of the image recorded by the camera and \( v \) be the vertical coordinate (Fig. 6). The origin of the \( u, \) \( v \) coordinate system is the normal projection of the grating center on the detector plane. Since the back of the detector is imaged onto the camera by a mirror, the direction of \( u \) in the camera image is the same as in the detector plane, it points toward increasing diffraction angles.
For diffraction in the horizontal plane \((y=v=0)\), the wavelength of the detected radiation can be expressed as a function of the pixel position \(u\) in screen coordinates

\[
\lambda = d \sin \left( a \tan \left( \frac{u-u_0}{A} \right) + \theta_0 \right).
\]

Here, \(u_0\) is the position of the origin of the \(u,v\) coordinate system, \(\theta_0=30^\circ\) is the angle between the detector plane normal and the VUV beam direction, \(d=100\) nm is the period of the grating, and the constant \(A\) depends on the magnification of the imaging system and the distance between the grating and the detector plane \((L=45\) mm).

Equations (2)–(6) are employed to derive the VUV spectrum from the two-dimensional detector image. They are also used to calibrate the detector angle \(\theta_0\) and the distance \(L\) between the MCP and the grating by analyzing a spectrum containing two or more known wavelengths. This calibration is usually more precise than the determination of \(\theta_0\) and \(L\) with standard measuring techniques since mechanical precision tools such as calipers and angle protractors are hard to use without damaging the fragile components. The supplementary material for this publication contains computer programs, written for GNU Octave scientific package, that can be used for parameter calibration and generation of VUV spectra as described above. The crescent diffraction patterns are shown in Fig. 5(b) by white lines. Integration of the image in Fig. 4(a) along these crescent lines results in the spectrum shown in Fig. 4(b).

The analysis of the diffraction pattern described above is used to estimate the spectrometer resolution. The width of the entrance slit of 50 \(\mu\)m contributes a wavelength uncertainty of approximately 0.08 nm at a wavelength of 50 nm. The resolution is further affected by the spot size of the electron bunch of about 70 \(\mu\)m generated by the MCP assembly and by the resolution of the digital camera used for imaging. The combined wavelength uncertainty is estimated to be \(\Delta \lambda=0.24\) nm \((\Delta E=120\) meV) at a wavelength of \(\lambda=50\) nm \((24.8\) eV) corresponding to a resolving power of \(\lambda/\Delta \lambda=210\). The spectral resolution varies across the detector from \(\Delta \lambda=0.13\) nm \((\Delta E=12\) meV) at the lower-energy side \((\lambda=80\) nm, \(E=15.5\) eV) to \(\Delta \lambda=0.25\) nm \((\Delta E=1.6\) eV) at the high-energy side \((\lambda=10\) nm, \(E=124\) eV).

IV. INTENSITY CALIBRATION

To extract relative intensities from the recorded spectra, it is necessary to account for three factors that introduce a wavelength dependence in the spectrometer detection efficiency: (i) the wavelength dependence of the MCP quantum detection efficiency (QDE), (ii) the angular dependence of the QDE, and (iii) the diffraction efficiency of the transmission grating.

The wavelength and angular dependence of MCP quantum detection efficiencies have been studied both experimentally and theoretically. For MCPs similar to those used in our imaging system, both angular and wavelength dependences of the QDEs are given by Siegmund et al. The wavelength dependence from Fig. 2 of Ref. 23 is plotted in Fig. 7(a) as a solid line. The measured QDE angular dependence from Fig. 3 of Ref. 23 covers a range of graze angles \(\phi=0^\circ -25^\circ\). The angular dependence of the QDE at larger graze angles is proportional to \(\cot(\phi)\). An empirical fit function with this asymptotic dependence is used to calculate the QDE angular dependence \(Q(\phi)\) across the entire range of incidence angles \(\phi=0^\circ -40^\circ\) of the spectrometer setup

\[
Q(\phi) = Q_0 (1 - e^{-\phi/\phi_0}) \cot(\phi),
\]

where \(\phi\) is the graze angle between the incident beam and the MCP pore axis. The constants \(Q_0=0.062\) and \(\phi_0=0.066\) are determined by a least squares fit. The experimental data of Ref. 23 together with a fit according to Eq. (8) are plotted in Fig. 7(b). Using Eqs. (2)–(6) and the efficiency data from Fig. 7, a two-dimensional calibration matrix is derived that assigns a total detection efficiency to every point on the detector. The calculation takes into account that the pores of the MCPs are tilted vertically at an angle of \(8^\circ\).
The detector images are integrated along the diffraction pattern in the vertical dimension after correcting for angular and wavelength dependence of the QDE. Apart from these corrections it is only necessary to account for the first order diffraction efficiency in the horizontal dimension. This efficiency is calculated using the “x-ray interaction with matter” calculator of the Center for X-ray Optics (CXRO) at Lawrence Berkeley National Laboratory. The transmission curves for the 100 nm and 4 μm thick Al filters are shown in Fig. 7(a) as a dash-dotted line.

By normalizing the measured spectrum using the Al filter transmission curve, the spectrum of the HHG source upstream from the filter is derived. The filter transmission curves are calculated using the x-ray interaction with matter calculator of the CXRO. The transmission curves for the 100 nm and 4 μm thick Al filters are shown in Fig. 7(a) as dashed and dotted lines, respectively.

V. CHARACTERIZATION OF A HHG-BASED FEMTOSECOND VUV LIGHT SOURCE

The performance of the spectrometer and beam profiler is demonstrated by probing the spatial beam profile of a HHG-based VUV light source and the dependence of the VUV spectrum on the temporal chirp of the IR driver pulse. A typical VUV beam profile is shown in Fig. 8. The honeycomb structure in the image is a result of the MCP channel packing geometry. The beam profile has an elliptical, vertically elongated shape. The side panels in Fig. 8 show the intensity distributions along the vertical and horizontal axes, derived by integrating the two-dimensional beam profile along the horizontal and vertical axes, respectively. Fits to Gaussian distribution functions (smooth solid lines) lead to beam full widths at half maximum (FWHMs) of 4.0 mm (vertically) and 2.5 mm (horizontally). The beam analyzer is positioned 2.40 m away from the HHG source. Correspondingly, the far-field divergence angle $\Theta_{\text{HH}}$ is on the order of $1–2$ mrad. The IR beam focusing geometry corresponds to a far-field divergence of $\Theta_{\text{IR}}=10$ mrad. A Gaussian beam description requires the beam divergence for a fixed beam waist to scale exactly with the wavelength, corresponding to a divergence ratio of 15–27 between the fundamental IR driving beam and the 15th to 27th harmonic. However, the beam waist for HH is smaller than for the IR driver since only the regions of highest intensities contribute to HHG. This reduction of the HH source volume compared to the focal size of the IR driver leads to an increased divergence of the HH beam as observed.

The elliptical shape of the HH beam profile is the result of an astigmatic focusing geometry. The IR beam is focused by a concave mirror with a 4 m radius that reflects the driver pulse at incidence angles of 16 mrad (horizontally) and 0 mrad (vertically). The IR beam passes through the meridional and the sagittal focus before it enters the gas cell, the foci being placed at a distance of ≈2–4 mm from the cell entrance aperture. This upstream focusing geometry is known to yield the best HHG efficiency. The geometry implies that HHs are generated closer to the sagittal than the meridional focus, where the astigmatic beam is horizontally elongated. The HH source volume is therefore more strongly confined in the vertical than in the horizontal direction. Gaussian beam propagation results in a larger far-field divergence in the vertical direction and a smaller in the horizontal direction, leading to the observed elliptical beam profile.

The qualitative discussion of the beam profile is confirmed by the results of a numerical beam propagation simulation, illustrated in Fig. 9. Images (a) and (b) show intensity distributions of a simulated astigmatic beam close to the sagittal focus (a) and in the far field (b). The beam is simulated by introducing an astigmatic phase to a flat field Gaussian beam using a second order Zernike polynomial and propagating the focused beam through the focal region using the LIGHTPILES software package. The far field intensity distribution is round, as expected, because the larger divergence of the beam in the vertical plane after the focus is compensated by the astigmatic phase distribution. A HH beam is simulated by keeping the phase profile of the IR beam and raising the
beam intensity to the fifth power. This procedure reflects the correspondence between the spatial phase profile of the IR beam and the HH beam and accounts for the nonlinear interaction leading to HH generation, which is expected to scale approximately with the fifth power of the driving IR intensity. The sagittal focus profile of this beam is shown in Fig. 9. After propagating the same distance as the beam in Figs. 9a and 9b, the simulated HH beam emerges with a vertically elongated shape [Fig. 9d] as is observed in the experiment.

This example demonstrates that the VUV beam profiler provides detailed information on the HHG source conditions and the HH beam propagation. This information is vital for the design of experiments that employ this novel class of light sources and for establishing reproducible light source conditions in day-to-day operations.

Operation of the spectrometer is demonstrated by recording a series of HH spectra generated by driving laser pulses with varying spectral chirps (Fig. 10). The chirp is modified by adjusting the position of one of the gratings in the compressor stage of the chirped-pulse laser amplifier system, while keeping the pulse energy constant. The HH spectrum is changing significantly as the spectral chirp is varied. The shapes of individual peaks are changing from a three peak structure at large negative chirps to a single intense peak at near-zero chirps. For large positive chirps, the harmonic peaks are split again, exhibiting double-peak structures.

A detailed picture of the driver chirp dependence of the HH spectrum can be seen in Fig. 11, which shows a waterfall representation of the data of Fig. 10 for the wavelength range of the 21st harmonic. The solid circles correspond to the camera pixels covered by the 21st harmonic and the group velocity dispersion (GVD) values are given on the left next to the base lines of the corresponding spectra. To guide the eye, the circles are connected by lines. Figure 11 demonstrates that spectral features spaced by less than a nanometer can easily be resolved by the spectrometer. In fact, the shapes of the peaks are not determined by the spectrometer resolution but by the HH generation conditions. In all spectra the separation of features ranges from 1.0 to 1.3 nm.

It is known that variation of the spectral chirp of the driving laser pulse leads to spectral shifts and broadening of individual HH peaks. The relation between HHG and the fundamental pulse chirp has previously been studied by several groups. These works mostly concentrate on the positions of the HH peaks and their width but do not discuss the splitting, even though it is observed experimentally and appears in theoretical calculations of the single-atom response in HHG (Fig. 3 of Ref. 34).

Recently, the structure of HH spectra has been theoretically analyzed by Liu et al. Their calculations predict that interference effects between several quantum paths lead to a strong dependence of the HH spectrum on the spectral chirp of the IR driver pulse including the splitting of single harmonic peaks. It is shown that HHG involves contributions from several electron recollisions including short and long trajectories as well as second, third, and higher order recollisions that occur when the electron does not recombine on the first passage of the core. The spectrum of HH radiation is determined by constructive interference of photons produced during all half-cycles of the femtosecond driver pulse that have sufficient intensity to generate photons of a certain energy. In the case of zero driver pulse chirp, contributions from similar trajectories of all consecutive half-cycles have equal phase shifts and thus the phase matching is achieved for exact odd harmonics of the fundamental frequency of the driver pulse.

For chirped driver pulses, the phase shifts gradually change from half-cycle to half-cycle. This induces interfer-
ences between contributions from different trajectories and leads to modulations in the HH spectra similar to those shown in Figs. 10 and 11. Detailed calculations beyond the scope of this paper are needed for a quantitative comparison of theory and experiment.

VI. SUMMARY

A compact device is presented that allows for fast, non-intrusive in situ characterization of the photon energy spectrum and the spatial beam profile of laboratory-scale VUV light sources. The entire unit is mounted on a standard DN200 CF vacuum flange. The in-vacuum size of the device is less than 200 × 200 × 100 mm³. Performance of the apparatus is demonstrated by analyzing the beam profile and the photon energy spectrum of a femtosecond HHG light source. An astigmatic focusing geometry of the IR driver pulse results in an elliptical VUV beam profile in agreement with recent theoretical predictions that ascribe the chirp of the IR driver to quantum interferences between different electron trajectories in the strong-field driven HHG process.

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